

Please cancel claims 2 and 3 without prejudice or disclaimer of the subject matter thereof.

Please amend claims 8, 13 and 18 as follows:

8. (amended) A process for manufacturing a liquid crystal display device including a step of irradiating polarized UV light to an orientation film formed on a substrate while maintaining a temperature of the substrate higher than room temperature, wherein the temperature of the substrate is maintained by a stage associated with the substrate which heats and moves the substrate while the orientation film formed on the substrate is irradiated.

13. (amended) A process for manufacturing a liquid crystal display device including a step of irradiating polarized UV light to an orientation film formed on a substrate for a time period while maintaining a temperature of the substrate which is higher than room temperature, the time period being less than a time period when the substrate is not maintained at the higher temperature, wherein the temperature of the substrate is maintained by a stage associated with the substrate which heats and moves the substrate while the orientation film formed on the substrate is irradiated.

18. (amended) A liquid crystal display device including orientation film formed on a substrate, wherein the orientation film is irradiated by polarized UV light while heating of the substrate for orientation of the orientation film, wherein the heating is provided by a stage associated with the substrate which moves the substrate while the orientation film formed on the substrate is irradiated.